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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/805,102	03/14/2001	Takashi Kimura	P107400-00026	1508	
7590 09/19/2002					
ARENT FOX KINTNER PLOTKIN & KAHN, PLLC 1050 Connecticut Avenue, N.W., Suite 600 Washington, DC 20036-5339			EXAMINER		
			NGUYEN, JOSEPH H		
	•	•	ART UNIT	PAPER NUMBER	
			2815		

DATE MAILED: 09/19/2002

Please find below and/or attached an Office communication concerning this application or proceeding.

· · ·			/			
	Application No.	Applicant(s)				
	09/805,102	KIMURA, TAKASHI				
Office Action Summary	Examiner	Art Unit				
	Joseph Nguyen	2815				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a repl - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statute - Any reply received by the Office later than three months after the mailin earned patent term adjustment. See 37 CFR 1.704(b).  Status	136(a). In no event, however ly within the statutory minimu will apply and will expire SIX a, cause the application to be	r, may a reply be timely filed orm of thirty (30) days will be considered timely. (6) MONTHS from the mailing date of this communication.				
1) Responsive to communication(s) filed on	·					
2a) This action is <b>FINAL</b> . 2b) ☑ The	nis action is non-fina	I.				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims  4)   Claim(s) 1-9 is/are pending in the application.						
4) Of the above claim(s) <u>6-9</u> is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>1-5</u> is/are rejected.						
7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/o	or election requireme	ent.				
Application Papers						
9) The specification is objected to by the Examine	er.					
10)⊠ The drawing(s) filed on <u>14 March 2001</u> is/are: a)⊠ accepted or b)⊡ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
11) The proposed drawing correction filed on						
If approved, corrected drawings are required in reply to this Office action.						
12)☐ The oath or declaration is objected to by the Examiner.						
Priority under 35 U.S.C. §§ 119 and 120						
13)⊠ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a)⊠ All b)□ Some * c)□ None of:						
1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents have been received in Application No						
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.						
14) Acknowledgment is made of a claim for domest	14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).					
<ul> <li>a) ☐ The translation of the foreign language provisional application has been received.</li> <li>15)☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.</li> </ul>						
Attachment(s)						
<ol> <li>Notice of References Cited (PTO-892)</li> <li>Notice of Draftsperson's Patent Drawing Review (PTO-948)</li> <li>Information Disclosure Statement(s) (PTO-1449) Paper No(s)</li> </ol>	5) 🔲 N	oterview Summary (PTO-413) Paper No(s)  otice of Informal Patent Application (PTO-152)  ther:				

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## **DETAILED ACTION**

#### Election/Restrictions

Applicant's election of claims 1-5 in Paper No. 4 is acknowledged. Because applicant did not distinctly and specifically point out the supposed errors in the restriction requirement, the election has been treated as an election without traverse (MPEP § 818.03(a)). Therefore, claims 1-5 are hereby prosecuted whereas claims 6-9 are withdrawn from consideration.

## Claim Rejections - 35 USC § 112

Claims 3 and 5 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention. The term "may be" is not clearly defined in such a way that whether "a width of said stripe trench for injecting current provided in said first layer is smaller than a width of said stripe trench provided in said second layer" in claim 3 and "the width of said stripe trench provided in said first layer is smaller than the width of said stripe trench provided in said first layer is smaller than the width of said stripe trench provided in said second layer in claim 5" are not precisely determined herein. A correction of this term is required.

# Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

<sup>(</sup>e) the invention was described in-

<sup>(1)</sup> an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effect under this subsection of a national application published under section 122(b) only if the international application designating the United States was published under Article 21(2)(a) of such treaty in the English language; or

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(2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that a patent shall not be deemed filed in the United States for the purposes of this subsection based on the filing of an international application filed under the treaty defined in section 351(a).

Claims 1-5 are rejected under 35 U.S.C. 102(e) as being anticipated by Suyama et al.

Regarding claim 1, Suyama et al discloses on figure 1 a semiconductor laser comprising an n type clad layer 3; a p type clad layer 5; an active layer 4 sandwiched between by said n type clad layer and said p type clad layer; and a current constriction layer for current confinement and light confinement consisting of at least two layers 9, 10 which is disposed in either of said n type clad layer and said p type clad layer, wherein a first layer 9 of said current constriction layer closer to said active layer has a different conductivity type from a conductivity type of either said clad layers in which said current constriction layer is provided and is made of a material having almost the same refractive index as said clad layer, and wherein a second layer 10 of said current constriction layer farther from said active layer 4 is made of a material having a smaller refractive index than said first layer.

Regarding claim 2, Suyama et al discloses on figure 1 said first layer 9 of said current constriction layer is formed to function mainly as a current confinement layer and said second layer 10 thereof is formed to function mainly as a light confinement layer and a width of stripe trench 7 for injecting current provided in said first layer 9 is smaller than a width of a stripe trench provided in said second layer 10.

Regarding claim 3, Suyama et al discloses on figure 1 said stripe trench 7 is formed so as to have an inclined surface with respect to a width direction of said current

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constriction layer, so that a width of said stripe trench for injecting current provided in said first layer may be smaller than a width of said stripe trench provided in said second layer.

Regarding claim 4, Suyama et al discloses on figure 1 said inclined surface of said first layer 9 has a smaller inclination angle than said second layer 10.

Regarding claim 5, Suyama et al discloses on figure 1 the width of said stripe trench provided in said first layer 9 may be smaller than the width of said stripe trench provided in said second layer 10.

Note that the limitation "said stripe trench in said first layer and said stripe trench in said second layer are provided in different steps" is merely product by process and therefore not given patentable weight.

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

US Patent 5933443 to Mushiage et al discloses a semiconductor laser.

US Patent 594980 to Ashida discloses a semiconductor laser.

## Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Joseph Nguyen whose telephone number is (703) 308-1269. The examiner can normally be reached on Monday-Friday, 7:30 am- 4:30 pm

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Eddie Lee can be reached on (703) 308-1690. The fax phone numbers for

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the organization where this application or proceeding is assigned is (703) 308-7382 for regular communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

JN September 17, 2002

EDDIE LEE
SUPERVISORY PATENT EXAMINER
TECHNOLOGY CENTER 2800